

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:

Applicant : Kiwamu Kobayashi
Appln. No. : Unassigned
Filed : Herewith
Title : PROJECTION LENS SYSTEM AND PROJECTOR
Docket No. : 490376-005

Mail Stop Patent Application
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450


INFORMATION DISCLOSURE STATEMENT

Pursuant to 37 C.F.R. §1.56, the Examiner's attention is directed to the references listed on the attached Information Disclosure Citation. Copies of the U.S. references listed on the Information Disclosure Citation are not enclosed due to the waiver of this requirement for applications filed after June 30, 2003. A copy of the foreign reference is enclosed.

It is to be understood that the present submission of art is in no way intended to be a waiver of any arguments or defenses available to the applicant under the rules of the U.S. Patent and Trademark Office and the statutes of the United States.

No fee is required. The Commissioner is authorized to charge any additional fees required by this paper or to credit any overpayment to Deposit Account No. 20-0809.

Respectfully submitted:

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INFORMATION DISCLOSURE CITATION

Docket: 490376-005	Appln. No.:
Applicant: Kiwamu Kobayashi	
Filed:	Group:

U.S. PATENT DOCUMENTS

Examiner		Document No.	Date	Name	Class	Sub	
		2002/0018301 A1	2/14/2002	Narimatsu et al.			
		6,587,279 B2	7/1/2003	Narimatsu et al.			
		5,900,987	5/4/1999	Kreitzer			
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FOREIGN PATENT DOCUMENT

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Examiner		Document No.	Date	Country	Class	Sub	Y	N
		2002-031754	1/31/2002	Japan				N

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

Examiner:	Date Considered:	

* Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.